Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2115	(silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone) near5 (anhydride anhydrous dianhydride dianhydrous polyanhydride polyanhydrous)	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:20
L2	554542	epox$6 diepox$6 polyepox$6 glycidyl$ diglycidyl$ polyglycidyl$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L3	150426	(functionaliz$4 modif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L4	72051	(silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L5	6835	L2 and L3 and L4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L6	17340	(functionaliz$4 modif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L7	4393	L2 and L6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 20:20
L8	6349	L5 L7	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:20
L9	845812	semiconductor chip wafer	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:21
L10	1416	(underfill underfilling underfilled (under adj (fill filled filling))) and (flux fluxing fluxed)	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:25
L11	26	l1.clm. and l9.clm.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:22
L12	8	l1.clm. and l2.clm. and l3.clm.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:24
L13	102	l2.clm. and l3.clm. and l9.clm.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:24
L14	248319	(underfill underfilling underfilled (under adj (fill filled filling))) (flux fluxing fluxed)	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:26
L15	21	l13 and l14.clm.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:25

L16	35421	(flux fluxing fluxed).clm.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:26
L17	4	115 and l16	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/28 20:26

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2901	(silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone) near5 (anhydride anhydrous dianhydride dianhydrous polyanhydride polyanhydrous)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:36
L2	554542	epox$6 diepox$6 polyepox$6 glycidyl$ diglycidyl$ polyglycidyl$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:37
L3	150426	(functionaliz$4 modif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:39
L4	56721	(silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:37
L5	72051	(silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:38
L6	6835	l2 and l3 and l5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:38
L7	93	l6 and l1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:38
L8	17340	(functionaliz$4 modif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:39
L9	4393	l2 and l8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:39
L10	75	l9 and l1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:40
L11	93	l7 l10	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:40

L12	9587	523/440.ccls. 523/443.ccls. 523/461.ccls. 523/466.ccls. 428/413.ccls. 428/414.ccls. 428/415.ccls. 428/416.ccls. 438/127.ccls. 525/523.ccls. 525/524.ccls. 525/525.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:54
L13	6	l7 and l12	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:55
L14	19782	l6 l8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:55
L15	6835	l6 l9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:56
L16	2202501	semiconductor chip wafer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:56
L17	1486	l15 and l16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:56
L18	68	l17 and (underfill underfilling underfilled (under adj (fill filled filling)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 20:02
L19	15	l17 and (underfill underfilling underfilled (under adj (fill filled filling))) and (flux fluxing fluxed)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 20:02
S1	5177	(functionaliz$4 mofif$4 treat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/13 15:13
S2	517873	epox$5 polyepox$5 diepox$5 glycidylether diglycidylether polyglycidylether (glycidyl adj ether) (diglycidyl adj ether) (polyglycidyl adj ether) diglycidyl$ polyglycidyl$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 14:49
S3	79396	nanometer nanometers (nano adj meter) (nano adj meters) "nano-meter" "nano-meters" "nano meter" "nano meters" (nano adj2 (size sized particle))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/13 13:58

S4	161	S1 and S2 and S3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:11
S5	16	S1 and S2 and S3 and (underfill underfilling underfilled (under adj (fill filled filling)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:04
S6	7381	523/440.ccls. 523/443.ccls. 523/461.ccls. 523/466.ccls. 428/413.ccls. 428/414.ccls. 428/415.ccls. 428/416.ccls. 438/127.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 12:59
S7	11	S6 and S1 and S2 and S3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:54
S8	83	rubinsztajn-slawomir.in. rubinsztajn-slawomir-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34
S9	15	tonapi-sandeep.in. tonapi-sandeep-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34
S10	843	campbell-john.in. campbell-john-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34
S11	10	prabhakumar-ananth.in. prabhakumar-ananth-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:35
S12	924	S8 S9 S10 S11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:56
S13	79	S12 and S2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:56
S14	13	S12 and S2 and S1 and (S3 "nm")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:58

S15	550	S2 and S1 and (S3 "nm")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:58
S16	52881	(S3 "nm") same (silica "sio2" (silicon adj (oxide dioxide)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:58
S17	385	S15 and S16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:59
S18	13	S15 and S16 and capping	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 14:59
S19	72	S15 and S16 and (phenyltrimethoxysilane (phenyl adj (trimethoxysilane)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:00
S20	29	S17 and S2.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:01
S21	21	S20 not S14	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:03
S22	16	("6486235" "6576718" "6555602" "6548189" "4217438" "5049596" "6180696").pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 12:55
S23	14695	(functionaliz$4 mofif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:49
S24	4	S22 and S2 and (S3 "nm") and S2.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:06
S25	117	S23 and S2 and (S3 "nm") and S2.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:05

S26	2	S22 and S2 and (S3 "nm") and S16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:07
S27	1080	S23 and S2 and (S3 "nm") and S16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:07
S28	79	S23 and S2 and (S3 "nm") and S16 and S2.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:07
S29	2	ep-385736-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:10
S30	1	wo-200146320-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:10
S31	0	wo-200448266-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:10
S32	1	wo-2004048266-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:10
S33	1	wo-2004048457-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:10
S34	5	S29 S30 S31 S32 S33	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:11
S35	5177	(functionaliz$4 mofif$4 treat$4) with (nanosilica "nano-silica" (nano adj silica) silica "sio2" (silicon adj (oxide dioxide))) with (colloidal sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:30
S36	161	S1 and S2 and S3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:14

S37	161	S35 and S2 and S3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:14
S38	83	rubinsztajn-slawomir.in. rubinsztajn-slawomir-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:27
S39	15	tonapi-sandeep.in. tonapi-sandeep-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:28
S40	193	gibson-david.in. gibson-david-a.in. gibson-david-alexander.in. gibson-david-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:28
S41	10	prabhakumar-ananth.in. prabhakumar-ananth-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:28
S42	10	mills-ryan.in. mills-ryan-c.in. mills-ryan-christopher.in. mills-ryan-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:35
S43	288	S38 S39 S40 S41 S42	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:30
S44	56	S43 and S2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:30
S45	68654	(nanosilica "nano-silica" (nano adj silica) silica "sio2" (silicon adj (oxide dioxide))) with (colloidal sol solgel)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:11
S46	13	S44 and S45	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:31
S47	13	S46 and solvent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:51

S48	2283	methoxypropanol (methoxy adj propanol)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 15:52
S49	8	S47 and S48	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:00
S50	424	S2 same solvent same S45	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:00
S51	14	S2 same solvent same S45 and S48	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:01
S52	958	S2.ab. and S45.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:02
S53	222	S2.ab. and S45.ab. and (solvent diluent).ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:03
S54	3	S2.ab. and S45.ab. and (solvent diluent).ab. and S48	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:02
S55	10313	(underfill underfilling underfilled (under adj (fill filled filling)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:04
S56	3	S53 and S54	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:04
S57	518832	cycloaliphatic alicyclic aliphatic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:04
S58	45	S53 and S57	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:05

S59	3	S53 and S57 and (silicone adj epoxy)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:07
S60	3	S53 and (silicone adj epoxy)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:06
S61	5	S53 and (silicone near2 epoxy)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:06
S62	15	S53 and S57 and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:08
S63	53143	(nanosilica "nano-silica" (nano adj silica) silica "sio2" (silicon adj (oxide dioxide))) with colloidal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:24
S64	517873	S2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:12
S65	1968	(S63 same S64) (S63.ab. and S64.ab.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:16
S66	708	S65 and (S2 same (S57 aromatic bisphenol silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:17
S67	135763	(functionaliz$4 mofif$4 treat$4 coat$4 capped endcapped capping endcapping silylat$4 hexamethyldisilazane) with (silica "sio2" (silicon adj (oxide dioxide)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:16
S68	366	S66 and S67	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:16
S69	625413	(S63 same S64 same (solvent diluent)) (S63.ab. and S64.ab. (solvent diluent).ab.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:17

S70	466	(S63 same S64 same (solvent diluent)) (S63.ab. and S64.ab. and (solvent diluent).ab.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:17
S71	293	S70 and (S2 same (S57 aromatic bisphenol silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:17
S72	287541	hardener curative crosslinker (cross adj linker) ((hardening curing crosslinking (cross adj linking)) adj2 (agent promoter))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:18
S73	149	S71 and S72	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:18
S74	47	S71 and (S72 same (novolac novolak cresol resorcinol hydroquinone))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/13 16:19
S75	53211	(nanosilica "nano-silica" (nano adj silica) silica "sio2" (silicon adj (oxide dioxide))) with colloidal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 13:00
S76	1473935	solvent diluent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:24
S77	518465	epox$5 polyepox$5 diepox$5 glycidylether diglycidylether polyglycidylether (glycidyl adj ether) (diglycidyl adj ether) (polyglycidyl adj ether) diglycidyl$ polyglycidyl$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:26
S78	402	S75 same S76 same S77	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:26
S79	188	S75.ab. and S76.ab. and S77.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:27
S80	466	S78 S79	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 10:27

S81	28522	S77 same (cresol novolak novolac)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 10:28
S82	98	S80 and S81	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 10:28
S83	12	("6486235" "6576718" "6555602" "6548189" "4217438").pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:40
S84	2	us-20030141592-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 12:55
S85	2	us-20030164555-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 12:55
S86	2	us-20030171456-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 12:56
S87	6	S84 S85 S86	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:40
S89	9506	523/440.ccls. 523/443.ccls. 523/461.ccls. 523/466.ccls. 428/413.ccls. 428/414.ccls. 428/415.ccls. 428/416.ccls. 438/127.ccls. 525/523.ccls. 525/524.ccls. 525/525.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 19:54
S90	1133	((S75 same S77) (S75.ab. and S77.ab.)) and S76	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 13:00
S91	98	S89 and S90	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 13:01
S92	11067	(functionaliz$4 mofif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:43

S93	518465	epox$5 polyepox$5 diepox$5 glycidylether diglycidylether polyglycidylether (glycidyl adj ether) (diglycidyl adj ether) (polyglycidyl adj ether) diglycidyl$ polyglycidyl$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:50
S94	2835	S92 and S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:50
S95	4400	(flux fluxing) same S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:50
S96	13	S94 and S95	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:51
S97	55553	(silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 14:53
S98	781	((S93 same S97) (S93.ab. and S97.ab.)) and S92	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 15:10
S99	19	S98 and (flux fluxing)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:08
S100	16	S98 and (flux fluxing) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:44
S101	83	rubinsztajn-slawomir.in. rubinsztajn-slawomir-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34
S102	843	campbell-john.in. campbell-john-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34
S103	16	tonapi-sandeep.in. tonapi-sandeep-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:34

S104	10	prabhakumar-ananth.in. prabhakumar-ananth-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:35
S105	10	mills-ryan.in. mills-ryan-c.in. mills-ryan-christopher.in. mills-ryan-$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:35
S106	932	S101 S102 S103 S104 S105	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:35
S107	13	S106 and S92 and S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:36
S108	8	S107 and (flux fluxing) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:37
S109	9506	523/440.ccls. 523/443.ccls. 523/461.ccls. 523/466.ccls. 428/413.ccls. 428/414.ccls. 428/415.ccls. 428/416.ccls. 438/127.ccls. 525/523.ccls. 525/524.ccls. 525/525.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:37
S110	77	S109 and S92 and S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:37
S111	10	S110 and (flux fluxing) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:38
S112	2	us-20030141592-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:40
S113	2	us-20030164555-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:40
S114	2	us-20030171456-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/16 16:40

S115	6	S112 S113 S114	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:40
S116	2	us-20020089067-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:41
S117	1	wo-2003075338-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:41
S118	8	("6566234" "6518677" "6399426" "6335571" "6297560" "6121689").pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:42
S119	2	us-20030124378-$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:42
S120	18	S115 S116 S117 S118 S119	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:43
S121	0	S120 and S93 and S92	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:43
S122	12652	(functionaliz$4 modif$4 treat$4 coat$4) with (silica "sio2" (silicon adj (oxide dioxide))) with (colloidal colloid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/10/28 19:37
S123	0	S120 and S93 and S122	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:44
S124	1585	S122 not S92	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:44
S125	382	S124 and S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:44

S126		6	S125 and (flux fluxing) and (solvent diluent)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/08/16 16:44